

LIST OF REFERENCES CITED BY APPLICANT

Atty Docket No.: 4100-98

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Applicant: Alfons SCHUSTER et al.

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U.S. PATENT DOCUMENTS

*Ex. Ints.		Document No.	Date	Name	Class	Subclass	Filing Date
	AA						
	AB						
	AC						
	AD						
	AE						

FOREIGN PATENT DOCUMENTS

*Ex. Ints.		Document No.	Date	Country	Name	Class	Subclass	Translation Yes/No
	AF	0 099 264	1/25/84	Europe	Doyle			Yes
	AG	0 580 394	1/26/94	Europe	Lewis			Yes
	AH	101266	2/22/84	Europe	Love			
	AI							
	AJ							

OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, Etc.)

	AK		"Technologie des Offsetdrucks", Riedl et al.; VEB Fachbuchverlag Leipzig; pg. 105-111; 1989.
	AO		
	AP		

EXAMINER:

DATE CONSIDERED: 8/25/98

* EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.